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(54) **Organic silicon compounds and cosmetic compositions.**

(57) Novel organic silicon compounds having a UV absorbing benzotriazole or benzophenone skeleton are provided comprising $R^1_3SiO_{1/2}$ and SiO_2 units as essential units, 0 to 20 mol% of $R^2SiO_{3/2}$ and R^3_2SiO units, and 0 to 20 mol% of R^3_2SiO units. The siloxane units are present in a molar ratio : $(R^1_3SiO_{1/2} + R^2SiO_{3/2} + R^3_2SiO)/SiO_2$ of from 0.5 to 1.5. A benzotriazole or benzophenone-bearing group constitutes 1 to 33 mol% of the total quantity of the organic groups represented by R^1 , R^2 and R^3 while the remainder is a monovalent saturated or unsaturated organic group or groups having 1 to 18 carbon atoms. Cosmetic compositions containing the same compounds have improved UV absorbing capacity.

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This invention relates to organic silicon compounds having a benzotriazole or benzophenone skeleton, exhibiting improved ultraviolet absorption and film forming ability, and offering a pleasant feel when blended in cosmetics. It also relates to cosmetic compositions containing the same.

Heretofore, ultraviolet (UV) absorbents having a benzotriazole or benzophenone skeleton have been used as additives to medical and cosmetic compositions as well as resin compositions.

These compounds having a benzotriazole or benzophenone skeleton useful as UV absorbents suffered from the problems that the amount of absorbents blended should be limited due to their poor dispersion and solubility in base compounds and bleeding could occur due to their dispersion instability.

Various proposals were made for improving the dispersion and dissolution of these compounds. For example, Japanese Patent Application Laid-open (JP-A) Nos. 21391/1982, 21432/1982, 10591/1983, 213075/1983, 111360/1986, and 187740/1987 disclose compounds of benzotriazole or benzophenone skeleton having alkoxysilyl groups incorporated therein. Due to the presence of alkoxysilyl groups, these compounds are susceptible to hydrolysis and lack stability. Medical and cosmetic compositions having these compounds blended therein have unpleasant feel on use since hydrolyzed products of these compounds are stimulative to the skin and mucous membranes.

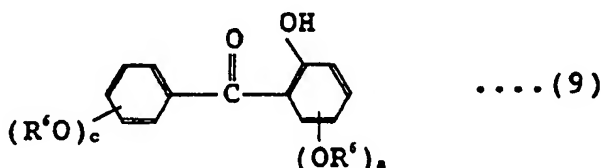
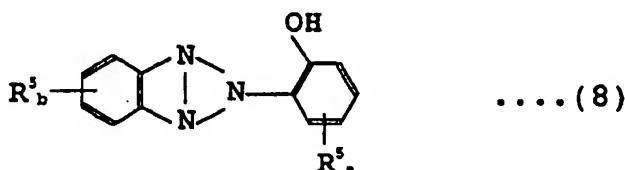
For further improvement in stability, hydrolysis resistant compounds were proposed as disclosed in Japanese Patent Publication No. 50074/1977, JP-A 230681/1988, and Japanese Patent Application Nos. 64485/1989 and 12874/1990, for example. These compounds are unsusceptible to hydrolysis, but oily and less likely to form films.

JP-A 21391/1982 discloses a method for forming films by applying compounds having a benzotriazole or benzophenone skeleton to plastics and subjecting the compounds to hydrolysis to form films. This method is less consistent since film forming rate and film state vary with the surrounding atmosphere. A hygienic problem occurs since alcohols generate upon film formation.

There is a need for developing UV absorbing compounds free of the above-mentioned problems.

Therefore it would be advantageous to provide novel and improved organic silicon compounds capable of absorbing UV, forming a film, and providing a pleasant feel when blended in cosmetic and similar compositions. It would also be desirable to provide a cosmetic composition containing the same.

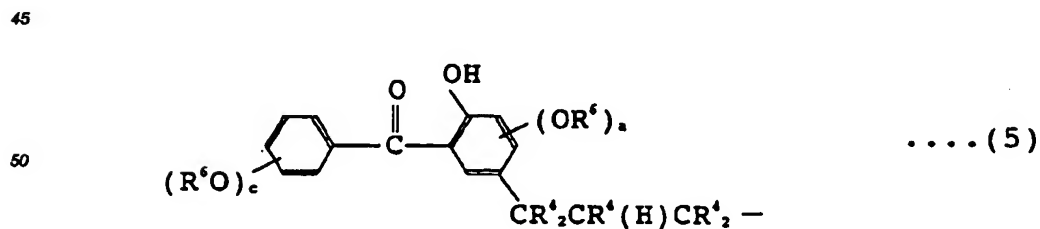
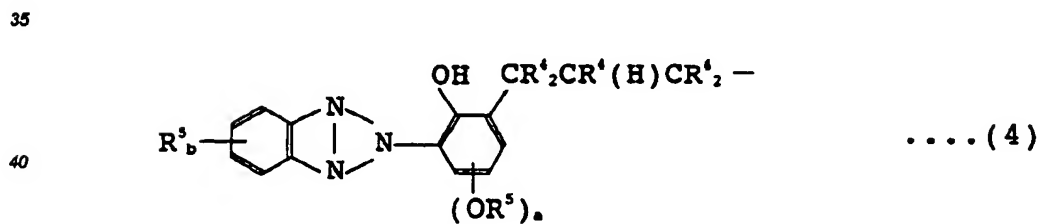
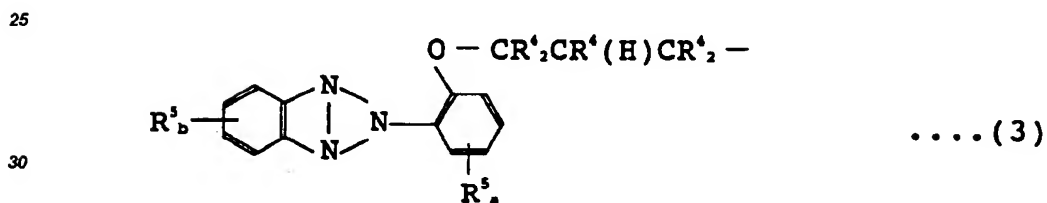
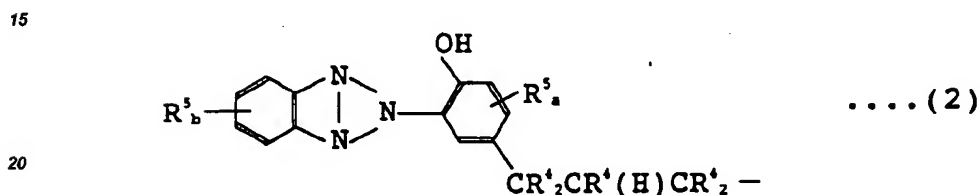
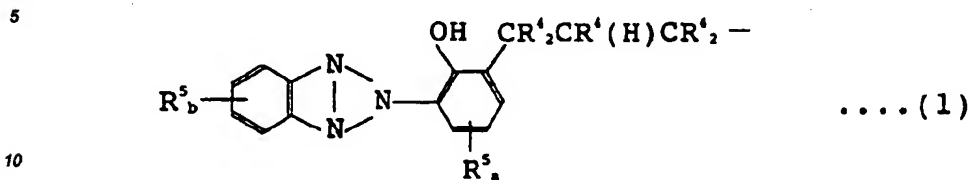
We have found that by starting with a compound having a UV absorbing benzotriazole or benzophenone skeleton represented by the following formula (8) or (9):



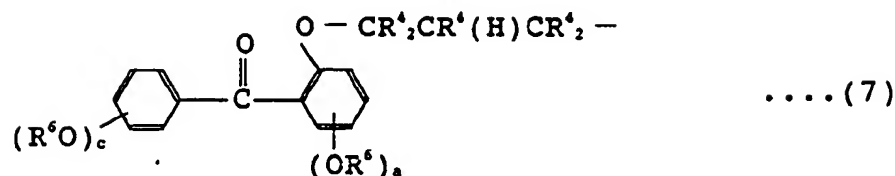
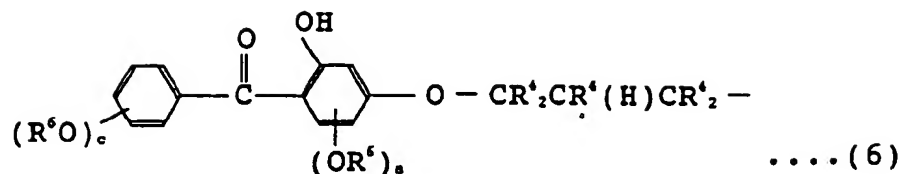
converting the phenol component of the compound into an allyl ether derivative and if desired, further converting the allyl ether derivative into an allyl derivative through thermal rearrangement reaction, reacting either of the derivatives with a hydrosilane compound having a hydrolyzable halogen atom or alkoxy group, and then subjecting the reaction product to hydrolysis reaction with a hydrolyzable chlorosilane, chloropolysiloxane, alkoxysilane, alkoxypolysiloxane or alkoxy polysilicate or polycondensation reaction with a non-hydrolyzable organopolysiloxane, there is obtained an organic silicon compound having a benzotriazole or benzophenone skeleton as defined below.

The present invention provides an organic silicon compound having a benzotriazole or benzophenone skeleton, comprising $R^1_3SiO_{1/2}$ and SiO_2 units as essential units and $R^2SiO_{3/2}$ and R^3_2SiO units as optional units. The amounts of $R^2SiO_{3/2}$ and R^3_2SiO units each range from 0 to 20 mol% of the entire compound. These siloxane units are present in a molar ratio: $(R^1_3SiO_{1/2} + R^2SiO_{3/2} + R^3_2SiO)/SiO_2$ of from 0.5 to 1.5. Among the

organic groups represented by R^1 , R^2 and R^3 , 1 to 33 mol% of the total quantity thereof is selected from the groups of the following structural formulae (1) through (7), the remainder being a monovalent saturated or unsaturated organic group having 1 to 18 carbon atoms.



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In formulae (1) through (7), R^4 is a hydrogen atom or a monovalent saturated hydrocarbon group having 1 to 5 carbon atoms,

R^5 is a monovalent saturated or unsaturated organic group having 1 to 18 carbon atoms, a halogen atom, or an alkoxy, carboxy, hydroxy, or amino group,

R^6 is a hydrogen atom or a monovalent saturated or unsaturated hydrocarbon group having 1 to 10 carbon atoms,

letter a is an integer of from 0 to 3, b is an integer of from 0 to 4, and c is an integer of from 0 to 5.

Preferred compounds having a benzotriazole or benzophenone skeleton have improved UV absorbing capacity and are capable of readily forming tack-free, crack-free, even films. When blended in cosmetic compositions, the compounds are well dispersible, soluble, and spreadable and give pleasant feel on use. Therefore, cosmetic compositions containing the organic silicon compounds are also contemplated herein.

BRIEF DESCRIPTION OF THE DRAWINGS

FIGS. 1 and 2 are the IR and UV absorption spectra of the organic silicon compound obtained in Example 1, respectively.

FIGS. 3 and 4 are the IR and UV absorption spectra of the organic silicon compound obtained in Example 2, respectively.

DETAILED DESCRIPTION OF THE INVENTION

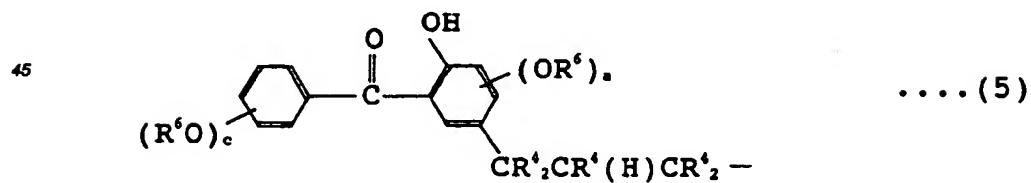
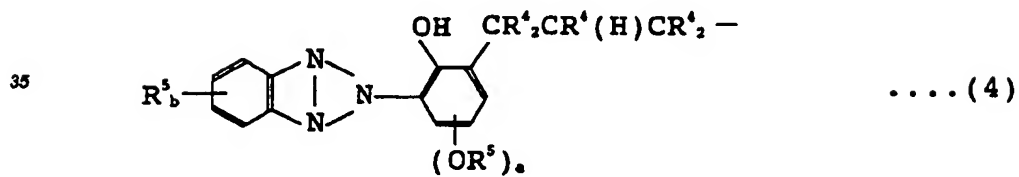
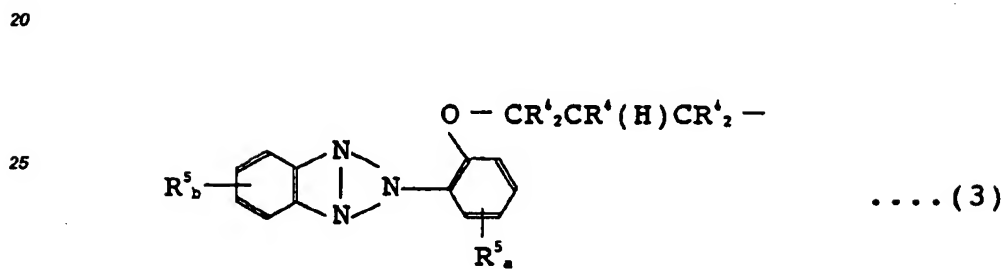
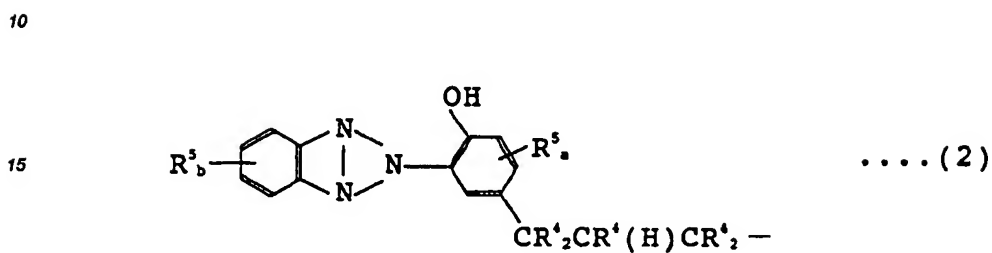
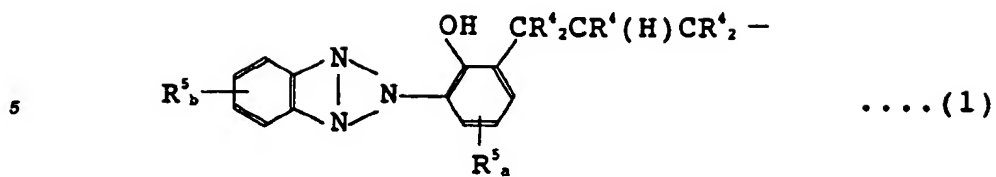
According to the present invention, organic silicon compounds are defined as comprising $\text{R}^1_3\text{SiO}_{1/2}$ and SiO_2 units as essential units and $\text{R}^2\text{SiO}_{3/2}$ and R^3_2SiO units as optional units. The amounts of $\text{R}^2_2\text{SiO}_{3/2}$ and R^3_2SiO units each range from 0 to 20 mol% of the entire compound. These siloxane units are present in a molar ratio:

$$(\text{R}^1_3\text{SiO}_{1/2} + \text{R}^2\text{SiO}_{3/2} + \text{R}^3_2\text{SiO})/\text{SiO}_2$$

of from 0.5/1 to 1.5/1, preferably from 0.6/1 to 1.3/1. If this ratio is less than 0.5/1, the resulting compounds would form less even films which are too hard and susceptible to cracking. If this ratio is more than 1.5/1, the resulting compounds would become tacky.

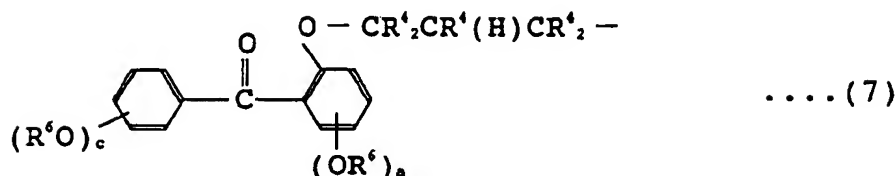
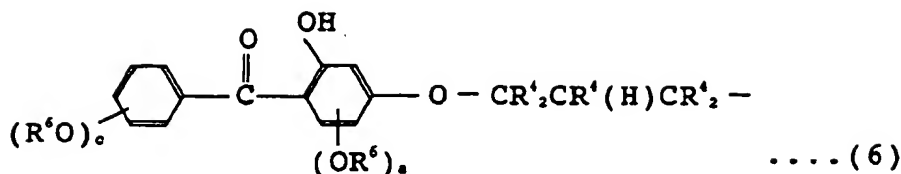
Among the siloxane units, the $\text{R}^2\text{SiO}_{3/2}$ and R^3_2SiO units each are contained in amounts of from 0 to 20 mol% of the entire compound, preferably from 0 to 10 mol% of the entire compound. More than 20 mol% would result in poor solubility in organic solvent, difficulty to handle, and increased tackiness.

R^1 , R^2 and R^3 in the siloxane units of $\text{R}^1_3\text{SiO}_{1/2}$, $\text{R}^2\text{SiO}_{3/2}$ and R^3_2SiO are organic groups. The organic silicon compounds of the invention contain at least one group of structural formulae (1) through (7) in an amount of 1 to 33 mol%, preferably 1 to 20 mol% based on the total moles of the organic groups. If this content is less than 1 mol%, no effective UV absorbing capacity is imparted. If this content exceeds 33 mol%, the resulting compounds would be less dispersible and soluble in a base medium.



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In formulae (1) through (7), R^4 is a hydrogen atom or a monovalent saturated hydrocarbon group having 1 to 5 carbon atoms,

R^5 is selected from monovalent saturated or unsaturated organic groups having 1 to 18 carbon atoms, preferably 1 to 10 carbon atoms, halogen atoms, alkoxy, carboxy, hydroxy, and amino groups,

R^6 is a hydrogen atom or a monovalent saturated or unsaturated hydrocarbon group having 1 to 10 carbon atoms, preferably 1 to 8 carbon atoms,

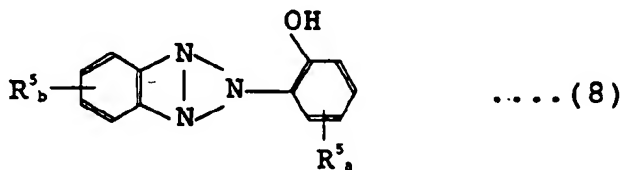
letter a is an integer of from 0 to 3, b is an integer of from 0 to 4, and c is an integer of from 0 to 5.

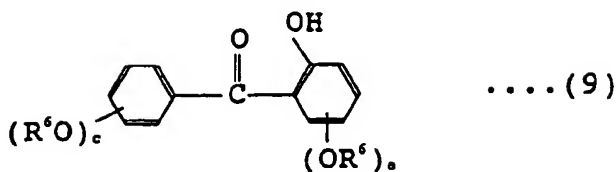
Examples of the group represented by R^4 include hydrogen atom, methyl, ethyl, propyl, butyl and pentyl groups. Examples of the group represented by R^5 include the same groups as represented by R^1 to R^3 , which will be described later, chlorine, bromine, and fluorine atoms, and methoxy, ethoxy, carboxy, hydroxy and amino groups. Examples of the group represented by R^6 include hydrogen atom; aliphatic hydrocarbon groups such as methyl, ethyl, propyl, butyl, pentyl, hexyl, heptyl, octyl, nonyl and decyl groups; saturated cycloaliphatic hydrocarbon groups such as cyclopentyl and cyclohexyl groups; and aromatic hydrocarbon groups such as phenyl and tolyl groups.

The remaining organic groups represented by R^1 , R^2 and R^3 are the same or different monovalent saturated or unsaturated organic groups having 1 to 18 carbon atoms, for example, aliphatic hydrocarbon groups such as methyl, ethyl, propyl, butyl, pentyl, hexyl, heptyl, octyl, nonyl, decyl, dodecyl, tetradecyl, hexadecyl, and octadecyl groups; saturated cycloaliphatic hydrocarbon groups such as cyclopentyl and cyclohexyl groups; and aromatic hydrocarbon groups such as phenyl and tolyl groups. Preferably, at least 50 mol% of the total moles of R^1 , R^2 and R^3 is a methyl group, and most preferably, the remaining organic groups are solely methyl.

The organic silicon compounds of the invention can be synthesized by the following process, for example.

The starting material is a compound having UV absorbing capacity of the following formula (8) or (9).

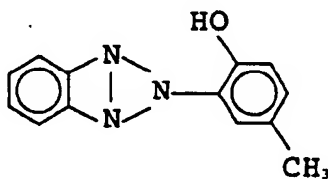




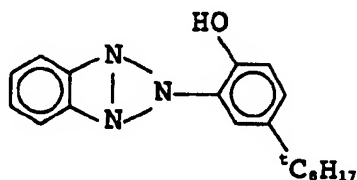
10 The phenol component of this compound is converted into an allyl ether derivative. If desired, the allyl ether derivative is further converted into an allyl derivative through thermal rearrangement reaction. Either of the derivatives is reacted with a hydrosilane compound having a hydrolyzable halogen atom or alkoxy group (addition reaction). The reaction product is then subject to hydrolysis reaction with a hydrolyzable chlorosilane, chloropolysiloxane, alkoxypolysiloxane or alkoxy polysilicate or polycondensation reaction with
 15 a non-hydrolyzable organopolysiloxane. There is obtained an organic silicon compound having a benzotriazole or benzophenone skeleton as defined above.

Examples of the compounds of formulae (8) and (9) used as the starting material are given below.

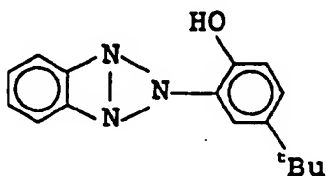
2-(2'-hydroxy-5'-methylphenyl)benzo-triazole



2-(2'-hydroxy-5'-tert-octylphenyl)-benzotriazole

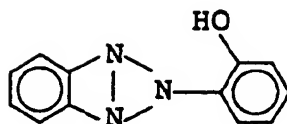


2-(2'-hydroxy-5'-tert-butylphenyl)-benzotriazole



2-(2'-hydroxyphenyl)benzotriazole

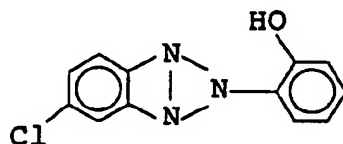
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2-(2'-hydroxyphenyl)-5-chlorobenzotriazole

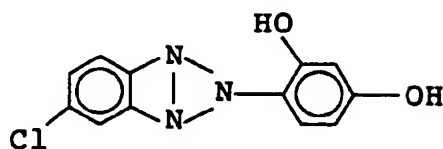
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2-(2',4'-dihydroxyphenyl)-5-chlorobenzotriazole

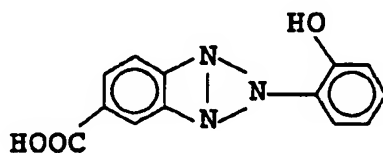
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2-(2'-hydroxyphenyl)-5-carboxybenzotriazole

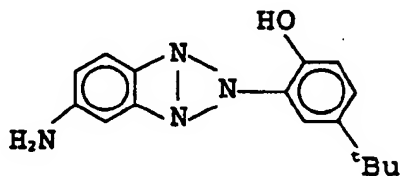
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2-(2'-hydroxy-5'-tert-butylphenyl)-5-aminobenzotriazole

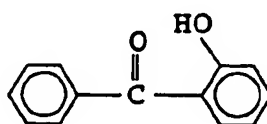
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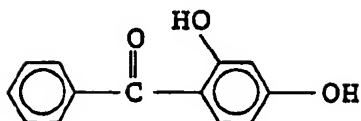
2-hydroxybenzophenone

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2,4-dihydroxybenzophenone

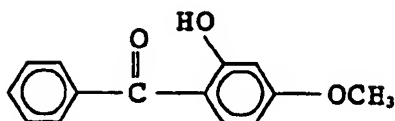
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2-hydroxy-4-methoxybenzophenone

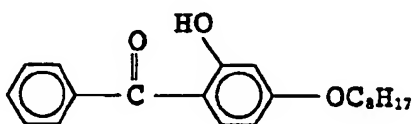
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2-hydroxy-4-octoxybenzophenone

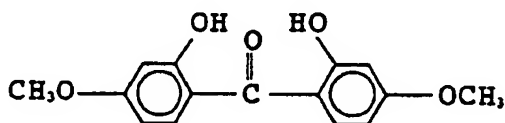
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2,2'-dihydroxy-4,4'-dimethoxybenzophenone

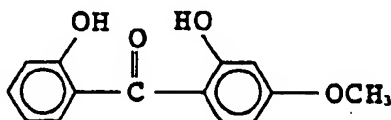
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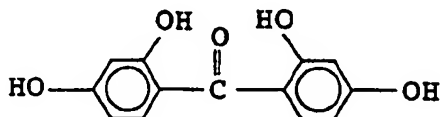
2,2'-dihydroxy-4-methoxybenzophenone

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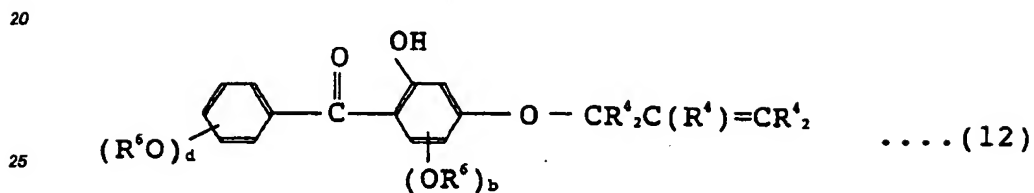
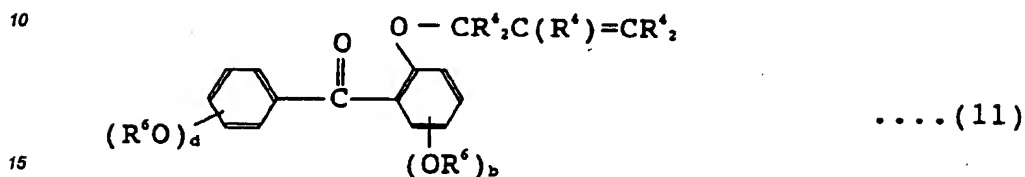
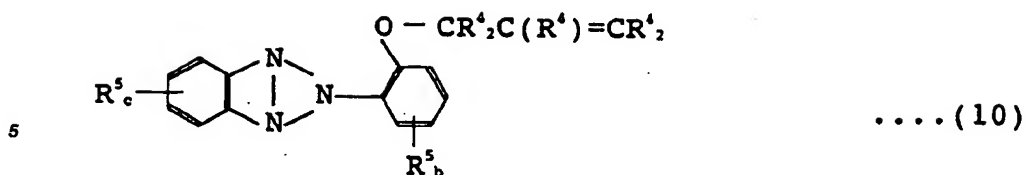


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2,2',4,4'-tetrahydroxybenzophenone



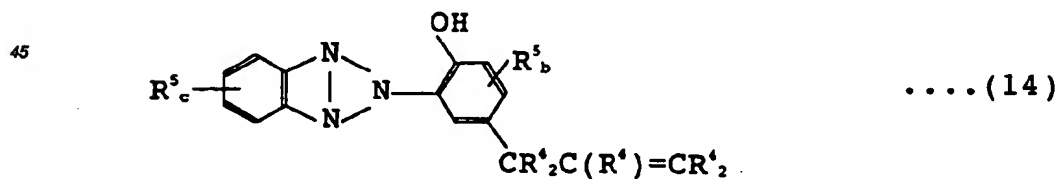
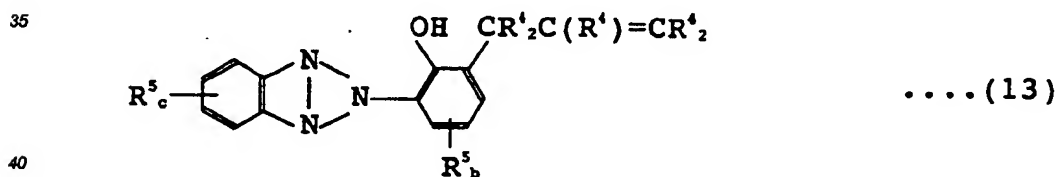
55 More illustratively, the compounds for formulae (8) and (9) can be reacted with halogenated ally compounds of the general formula: $\text{CR}^4_2=\text{C}(\text{R}^4)-\text{CR}^4_2-\text{X}$ wherein R^4 is as defined above and X is a chlorine atom, bromine atom, or iodine atom in basic conditions whereupon their phenol components are converted into allyl ether derivatives of the following general formulae (10) to (12).



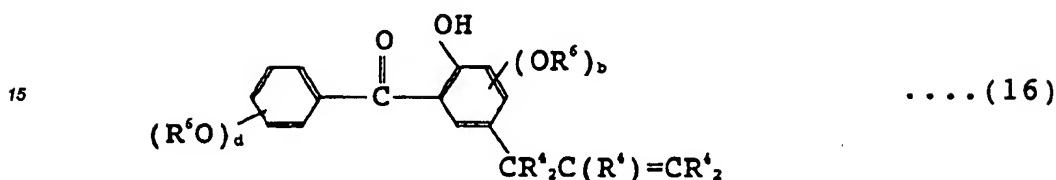
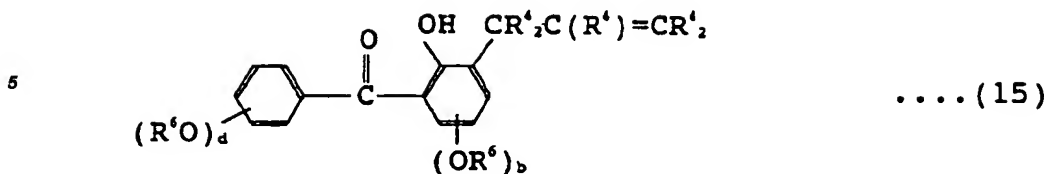
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Preferably, the compounds of formulae (8) and (9) are reacted with halogenated ally compounds by mixing them in a molar ratio of from 1:1 to 1:5, more preferably from 1:1 to 1:2 and heating at a temperature of 50 to 100°C for about 1 to about 20 hours.

The allyl ether derivatives of formulae (10) to (12) can be converted into allyl derivatives of the following general formulae (13) to (16) through thermal rearrangement reaction.



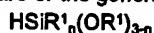
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20 The rearrangement reaction conditions are not critical, but desirably include a temperature of 150 to 300°C and a time of from 1 to 5 hours.

The allyl ether derivatives or the allyl derivatives are then subject to addition reaction with hydrosilane compounds having a hydrolyzable halogen atom or alkoxy group by mixing them preferably in a molar ratio of 1:1 to 1:5, more preferably 1:1 to 1:2.

25 The hydrosilane compounds used herein are of the general formula:



wherein R¹ is as defined above and n is equal to 0, 1 or 2, for example, alkoxy silanes such as trimethoxysilane, triethoxysilane, tripropoxysilane, methyldimethoxysilane, methyldiethoxysilane, methyldipropoxysilane, ethyldimethoxysilane, ethyldiethoxysilane, ethyldipropoxysilane, dimethylmethoxysilane, dimethylethoxysilane, dimethylpropoxysilane, diethylmethoxysilane, diethylethoxysilane, diethylpropoxysilane, phenyldimethoxysilane, phenyldiethoxysilane, phenyldipropoxysilane, diphenylmethoxysilane, diphenylethoxysilane, and diphenylpropoxysilane; and of the general formula:



wherein R¹ is as defined above, X is halogen, and n is equal to 0, 1 or 2, for example, chlorosilanes such as trichlorosilane, methyldichlorosilane, ethyldichlorosilane, dimethylchlorosilane, diethylchlorosilane, phenyldichlorosilane, and diphenylchlorosilane.

For the addition reaction, catalysts such as platinum compounds and palladium compounds are preferably added in catalytic amounts. Exemplary catalysts are chloroplatinic acid, rhodium complexes, and palladium complexes.

40 Prior to the addition reaction with hydrosilanes, the phenol component in the allyl ether derivative or allyl derivative molecule may be protected with an organic silicon group by reacting with a conventional silylating agent such as hexamethyldisilazane and N,O-bis(trimethylsilyl)-acetamide.

Finally, the addition reaction product is subject to hydrolysis reaction with a hydrolyzable chlorosilane, chloropolysiloxane, alkoxy silane, alkoxy polysiloxane or alkoxy polysilicate or polycondensation reaction with a non-hydrolyzable organopolysiloxane in a conventional manner. For example, hydrolysis or polycondensation reaction is carried out by charging a reactor with the addition reaction product, a hydrolyzable chlorosilane, chloropolysiloxane, alkoxy silane, alkoxy polysiloxane or alkoxy polysilicate or a non-hydrolyzable organopolysiloxane, organic solvent and acid, adding water to the reactor, and allowing the reaction to take place at room temperature or elevated temperatures.

50 Alternatively, hydrolysis or polycondensation reaction is carried out by charging a reactor with water, organic solvent and acid, adding a mixture of the addition reaction product and a hydrolyzable chlorosilane, chloropolysiloxane, alkoxy silane, alkoxy polysiloxane or alkoxy polysilicate or a non-hydrolyzable organopolysiloxane to the reactor, and allowing the reaction to take place at room temperature or elevated temperatures. An end organic silicon compound is obtained in this way. In addition to the last-mentioned step, the organic silicon compounds of the invention can be obtained by hydrosilylating the addition reaction product with a resinous compound having a Si-H bond.

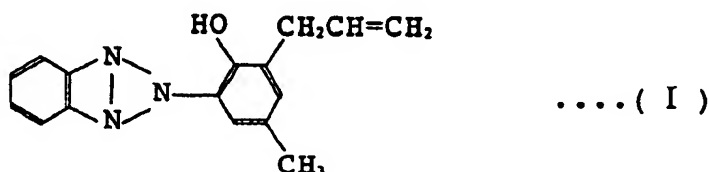
EXAMPLE

Examples of the present invention are given below by way of illustration and not by way of limitation.

5 Example 1

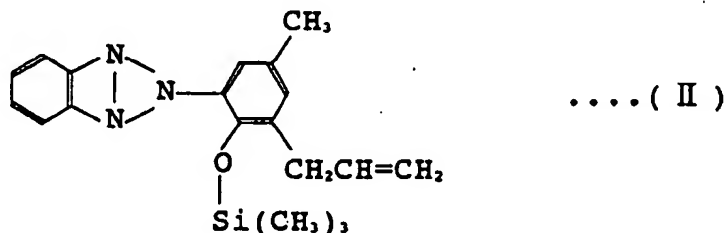
A reactor was charged with 98.4 grams of 2-(2'-hydroxy-5'-methylphenyl)benzotriazole and 250 grams of toluene. To the reactor 127 grams of a methanol solution containing 28% by weight of sodium methoxide was gradually added through a dropping funnel. After stirring for 30 minutes at room temperature, the contents were heated to 70 to 85°C for removing 100 grams of the solvent. The contents were cooled down to 40°C in flowing air whereupon 106.4 grams of allyl bromide was gradually added through a dropping funnel. The reaction mixture was heated under reflux for 2 hours. After the formed salt was removed by filtration, the product was washed with water, the solvent removed in vacuum, and the residue distilled in vacuum. At this point, the rearranged product was directly obtained without isolating the allyl ether derivative or intermediate. That is, upon distillation, the whole contents were kept under reflux for rearrangement without taking out any fraction until the effluent temperature exceeded 200°C. In this way, there was obtained 106.4 grams of a fraction at a distillation temperature of 211 to 222°C in a vacuum of 7 mmHg.

The fraction was recrystallized from 1000 grams of a solvent mixture of toluene and methanol in a weight ratio of 1:9. There was obtained 87.9 grams of an allyl derivative having the following formula (I).



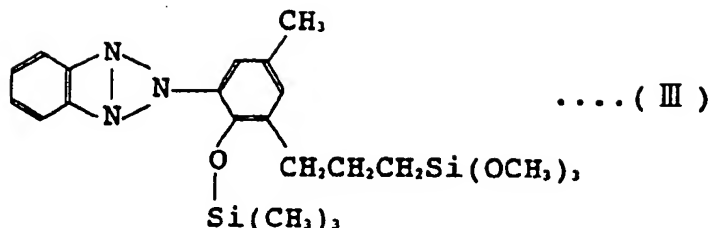
It was a white needle crystal product having a melting point of 100 to 102°C.

Next, a reactor was charged with 50 grams of allyl derivative (I), 100 grams of toluene, and 35 grams of N,O-bis(trimethylsilyl)-acetamide and heated under reflux for 4 hours. After the solvent was removed in vacuum, the residue was distilled, yielding 60.0 grams of a derivative having the following formula (II).



It was a clear, pale yellow liquid having a melting point of 210 to 217°C at a vacuum of 2 mmHg.

Next, a reactor was charged with 25.0 grams of derivative (II) and 30.0 grams of toluene. After the contents were heated to 80°C, 0.05 grams of a 2-propanol solution of 2% by weight chloroplatinic acid was added and 11 grams of trimethoxysilane was gradually added through a dropping funnel. After the completion of addition, the mixture was heated under reflux for 4 hours, and the solvent was removed in vacuum. Distillation of the residue yielded 24.7 grams of a derivative having the following formula (III).

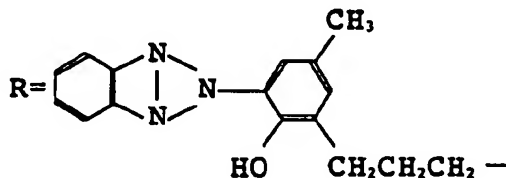


It was a clear, reddish yellow liquid having a melting point of 230 to 240°C at a vacuum of 4 mmHg.

Thereafter, a reactor was charged with 15.0 grams of derivative (III), 34.6 grams of Methyl Silicate 51® (methoxysilane oligomer, manufactured by Kolcoat K.K.), 19.6 grams of hexamethyldisiloxane, and 0.9 grams of methane sulfonate. To the reactor 11.1 grams of water was gradually added through a dropping funnel. After the completion of addition, the mixture was stirred for 30 minutes and after heated to 64 to 68°C, stirred for a further 5 hours. The reaction solution was cooled down to room temperature, combined with 50 grams of toluene, and washed with water. Removal of the solvent in vacuum resulted in 32.0 grams of an organic silicon compound in pale yellow solid form.

The IR and UV absorption spectra of the thus obtained organic silicon compound are shown in FIGS. 1 and 2. For the UV absorption spectroscopy, a solution containing 1.01 mg of the compound in 100 ml of ethanol was used.

This organic silicon compound was identified as consisting of three siloxane units: $(\text{CH}_3)_3\text{SiO}_{1/2}$, $\text{RSiO}_{3/2}$ and SiO_2 units wherein 4,1 mol% of the entire organic groups is a group represented by the following structural formula:



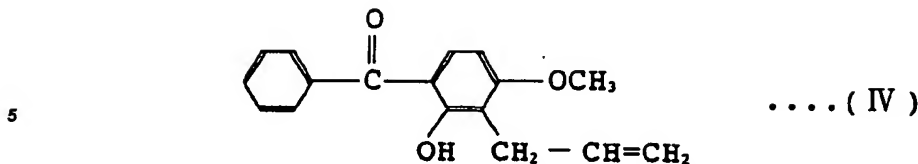
35 the siloxane units are present in a molar ratio: $[(\text{CH}_3)_3\text{SiO}_{1/2} + \text{RSiO}_{3/2}]/\text{SiO}_2 = 0.93$, and the content of $\text{RSiO}_{3/2}$ units is 5.7 mol% of the entire compound.

This compound was soluble in octamethylcyclotetrasiloxane. A solution containing 48% by weight of the compound therein was a yellow solution having a viscosity of 127 centistokes (cSt) at 25°C. Removal of the octamethylcyclotetrasiloxane from this solution left an even, tack-free, crack-free film.

40 Example 2

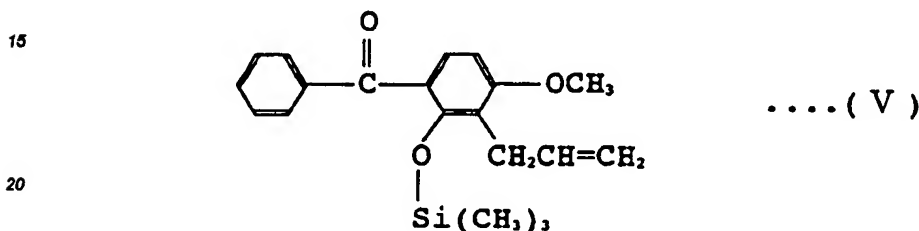
A reactor was charged with 45.6 grams of 2-hydroxy-4-methoxybenzophenone and 300 grams of toluene. To the reactor 46,3 grams of a methanol solution containing 28% by weight of sodium methoxide was gradually added through a dropping funnel while stirring for 30 minutes at room temperature. While admitting nitrogen gas into the reactor, the reactor was heated by an oil bath at 100°C for removing 48 grams of the solvent. The contents were cooled down to room temperature in flowing air whereupon 34,0 grams of allyl bromide and 100 grams of dimethylformamide were gradually added through a dropping funnel.

After the completion of addition, the reaction mixture was heated under reflux for 5 hours. The formed salt was removed by filtration and the product was washed with water. Further the solvent was removed in vacuum. The residue was heated at 240 to 250°C in a vacuum of 35 mmHg for one hour and then distilled, yielding 46.2 grams of an allyl derivative of the following formula (IV).



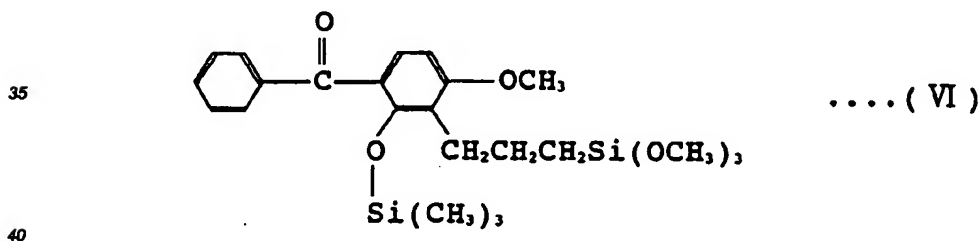
The allyl derivative (IV) had a melting point of 221 to 225°C in a vacuum of 9 mmHg.

10 Next, a reactor was charged with 39.2 grams of allyl derivative (IV), 40 grams of toluene, and 29.8 grams of N,O-bis(trimethyl-silyl)acetamide and heated under reflux for 4 hours. After the solvent was removed in vacuum, the residue was distilled, yielding 48.7 grams of a derivative having the following formula (V).



It was a clear, pale yellow liquid having a melting point of 178 to 180°C at a vacuum of 1 mmHg.

25 Next, a reactor as charged with 45.0 grams of derivative (V) and 50 grams of toluene. After the contents were heated to 80°C, 0.1 grams of a 2-propanol solution of 2% by weight chloroplatinic acid was added and 24.0 grams of trimethoxysilane was gradually added through a dropping funnel. After the completion of addition, the mixture was heated under reflux for 4 hours, and the solvent was removed in vacuum. Distillation of the residue yielded 55.6 grams of a derivative having the following formula (VI).



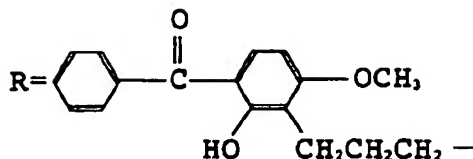
It was a clear, slightly yellow liquid having a melting point of 198 to 203°C at a vacuum of 3×10^{-2} mmHg.

Thereafter, a reactor was charged with 34.4 grams of derivative (VI), 78.8 grams of Methyl Silicate 51® (methoxysilane oligomer, manufactured by Kolcoat K.K.), 44.6 grams of hexamethyldisiloxane, and 2.3 grams of methane sulfonate. To the reactor 72.2 grams of water was gradually added through a dropping funnel. After the completion of addition, the mixture was stirred for 30 minutes and after heated to 64 to 68°C, stirred for a further 5 hours. The reaction solution was cooled down to room temperature, combined with 200 grams of toluene, and washed with water. Removal of the solvent in vacuum resulted in 58.3 grams of an organic silicon compound in pale yellow solid form.

50 The IR and UV absorption spectra of the thus obtained organic silicon compound are shown in FIGS. 3 and 4, respectively. For the UV absorption spectroscopy, a solution containing 1.00 mg of the compound in 100 ml of ethanol was used.

This organic silicon compound was identified as consisting of three siloxane units: $(\text{CH}_3)_3\text{SiO}_{1/2}$, $\text{RSiO}_{3/2}$ and SiO_2 units wherein 4.1 mol% of the entire organic groups is a group represented by the following structural formula:

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the siloxane units are present in a molar ratio: $[(\text{CH}_3)_3\text{SiO}_{1/2} + \text{RSiO}_{3/2}]/\text{SiO}_2 = 9.3$, and the content of $\text{RSiO}_{3/2}$ units is 5.7 mol% of the entire compound.

This compound was soluble in octamethylcyclotetrasiloxane. A solution containing 45% by weight of the compound therein was a yellow solution having a viscosity of 88 cSt at 25°C. Removal of the octamethylcyclotetrasiloxane from this solution left an even, tack-free, crack-free film.

The following examples illustrate the exemplary formulation of cosmetic products which were obtained by blending the organic silicon compounds of Examples 1 and 2.

Formulation 1: Oily foundation

Part (A)	% by weight
Kaolin	20.0
Titanium oxide	12.0
Sericite	8.0
Coloring pigment	suitable
Part (B)	% by weight
Carnauba wax	4.0
Dimethylpolysiloxane	5.0
(viscosity 50 cSt at 25°C)	
48% octamethylcyclotetrasiloxane	
solution of the organic silicon	
compound in Example 1	8.0
Octamethylcyclotetrasiloxane	42.0
Sorbitan sesquioleate	1.0
Part (C)	
Flavor	suitable

The ingredients of Part (B) were agitated at 70°C into a uniform solution, to which the ingredients of Part (A) were added and dispersed therein by agitation. After cooling, the mixture was milled three rounds in a three roll mill. Part (C) was finally added, obtaining an oily foundation.

The oily foundation was improved in UV absorption and well spreadable, offering a placid pleasant feel to

the skin.

Formulation 2: Solid foundation

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Part (A)	<u>% by weight</u>
Titanium oxide	20.0
Mica	36.0
Sericite	10.0
Talc	10.0
Coloring pigment	suitable

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Part (B)	<u>% by weight</u>
Dimethylpolysiloxane	12.5
(viscosity 50 cSt at 25°C)	
45% octamethylcyclotetrasiloxane	
solution of the organic silicon	
compound in Example 2	10.0
Lipophilic glycerin monooleate	1.5
Methyl p - hydroxybenzoate	suitable
Flavor	suitable

The ingredients of Part (A) were milled in a twin roll mill and then combined with Part (B) in uniform solution form and blended by agitation. The mixture was milled three rounds in a three roll mill, obtaining a solid foundation.

The solid foundation was improved in UV absorption and offered a placid pleasant feel to the skin.

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Formulation 3: Sun screen cream

Part (A)	<u>% by weight</u>
Octamethylcyclotetrasiloxane	40.0
48% octamethylcyclotetrasiloxane	
solution of the organic silicon	
compound in Example 1	20.0
Trimethylsiloxypolysilicate	25.0
Liquid paraffin	10.0
Carnauba wax	5.0

Part (B)

Flavor

suitable

The ingredients of Part (A) were agitated at 80°C into a uniform mixture, which was allowed to cool. Addition of Part (A) yielded a sun screen cream. It was improved in UV absorption and offered a placid pleasant feel to the skin.

Formulation 4: Sun screen emulsion

Part (A)	<u>% by weight</u>
Decamethylcyclopentasiloxane	7.0
45% octamethylcyclotetrasiloxane	
solution of the organic silicon	
compound in Example 2	3.0
Dimethylpolysiloxane	2.0
(viscosity 350 cSt at 25°C)	
Stearic acid	2.0
Self-emulsifying glycerin	1.0
monostearate	
Cetanol	1.0

Part (B)

% by weight

5	Pure water	72.5
	Triethanolamine	1.0
	Propylene glycol	3.0
10	Titanium oxide	5.0
	Bentonite	0.5
15	Methyl p - hydroxybenzoate	suitable

Part (C)

20	Flavor	suitable
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The ingredients of Part (A) were dissolved by agitation at 80°C. The ingredients of Part (B) were dispersed by agitation at 80°C. with stirring, the dispersion of Part (B) was gradually admitted into the solution of Part (A). The mixture was allowed to cool. Part (C) was finally added, obtaining a sun screen emulsion.

The sun screen emulsion had a placid pleasant feel to the skin.

Formulation 5: Hair cream

	Part (A)	<u>% by weight</u>
5	Methylphenylpolysiloxane (viscosity 20 cSt at 25°C)	17.0
10	48% octamethylcyclotetrasiloxane solution of the organic silicon compound in Example 1	3.0
15	Tsubaki oil	10.0
	Haze bee wax	5.0
20	Self-emulsifying glycerin monostearate	3.0
25	Polyoxyethylene sorbitan monostearate (20 EO)	3.0
	Reduced lanolin	1.5
30	Microcrystalline wax	2.0
	Methyl p-hydroxybenzoate	suitable
35	Part (B)	<u>% by weight</u>
	Pure water	51.0
40	Borax	0.5
	Glycerin	3.0
45	Carboxyvinyl polymer	0.2
	Part (C)	<u>% by weight</u>
50	Flavor	0.8

The ingredients of Part (A) were dissolved by agitation at 80°C. The ingredients of Part (B) were dissolved by agitation at 80°C. The solutions of Parts (A) and (B) were mixed and the mixture was cooled to 60°C. Part (C) was finally added to the solution, which was cooled to 30°C, obtaining a hair cream. The cream was improved in UV absorption and had a placid pleasant feel.

Formulation 6: Lipstick

	Part (A)	% by weight
5	Methylphenylpolysiloxane	46.5
	(viscosity 20 cSt at 25°C)	
10	45% octamethylcyclotetrasiloxane	
	solution of the organic silicon	
	compound in Example 2	10.0
15	Reduced lanolin	20.0
	Carnauba wax	4.5
20	Candellilla wax	9.0
	Seresine wax	2.5
25	Haze bee wax	1.5
	Cacao butter	4.0
	Sucrose fatty acid ester	2.0
30	Antioxidant	suitable
	Part (B)	
35	Allantoin	suitable
	Red No. 3 aluminum lake	suitable
40	Part (C)	
	Flavor	suitable

45 The ingredients of Part (A) were dissolved by agitation at 85°C. A portion of the solution was combined with the ingredients of Part (B). The mixture was milled three rounds in a three roll mill, obtaining a color paste. The color paste was added to the remainder of Part (A). The mixture was uniformly dispersed by means of a dispersing mixer and then combined with Part (C). The mixture was admitted into a mold and rapidly cooled, obtaining a lipstick. This lipstick had improved UV absorbing capacity, glossy appearance, and placid feel to the lip.

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Formulation 7: Eye shadow

	Part (A)	<u>% by weight</u>
5	Pearl agent	10.0
	Blue ultramarine	5.0
10	Part (B)	<u>% by weight</u>
	Dimethylpolysiloxane	28.0
15	(viscosity 20 cSt at 25°C)	
	Octamethylcyclotetrasiloxane	42.0
20	48% octamethylcyclotetrasiloxane solution of the organic silicon compound in Example 1	5.0
25	Reduced lanolin	5.0
30	Microcrystalline wax	5.0
	Part (C)	
35	Flavor	suitable

The ingredients of Part (B) were dissolved by agitation at 80°C. with stirring, the ingredients of part (A) were added to the solution and dispersed therein. Part (C) was added to the mixture. The mixture was milled three rounds in a three roll mill, obtaining a creamy eye shadow. It had improved UV absorbing capacity and placid feel to the skin.

Formulation 8: Mascara

45	Part (A)	<u>% by weight</u>
	Isoparaffin	20.0
50	Octamethylcyclotetrasiloxane	20.0
	45% octamethylcyclotetrasiloxane solution of the organic silicon compound in Example 2	7.0
55	Aluminum stearate	1.0

Part (B)

% by weight

Bentonite	15.0
Methylphenylpolysiloxane	7.0
(viscosity 20 cSt at 25°C)	
Candelilla wax	10.0
Hydrogenated polybuttene	5.0
Methyl p-hydroxybenzoate	suitable

Part (C)

% by weight

Kaolin	5.0
Black iron oxide	5.0

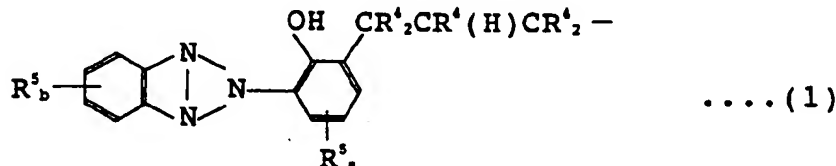
The ingredients of part (A) were agitated into a gel at 80°C. The ingredients of Part (B) were uniformly dispersed by agitation at 80°C. The dispersion was added to the gel of Part (A) and uniformly dispersed therein. After cooling, the ingredients of Part (C) were added. The mixture was milled three rounds in a three roll mill, obtaining a mascara. It had improved UV absorbing capacity and placid feel to the skin.

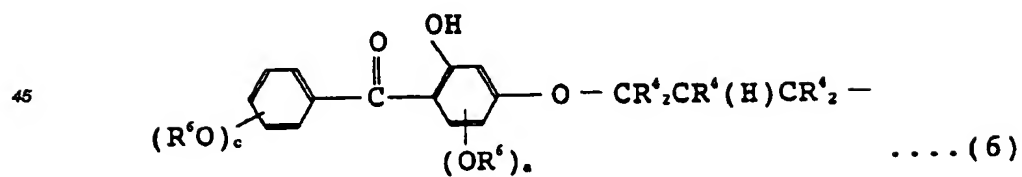
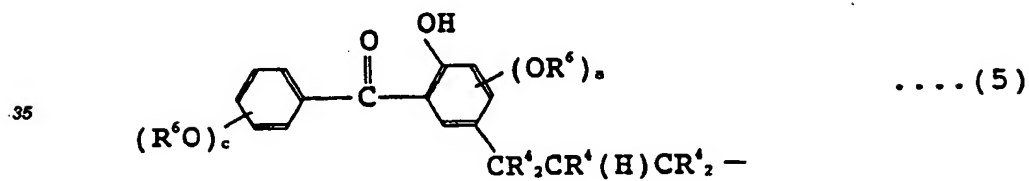
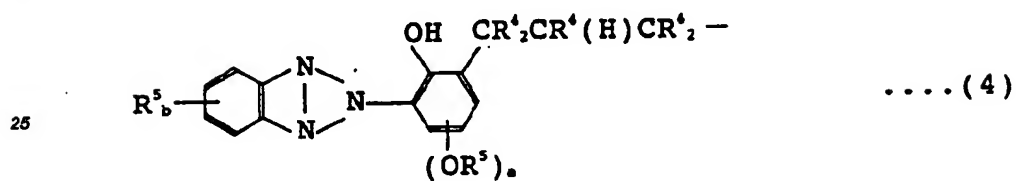
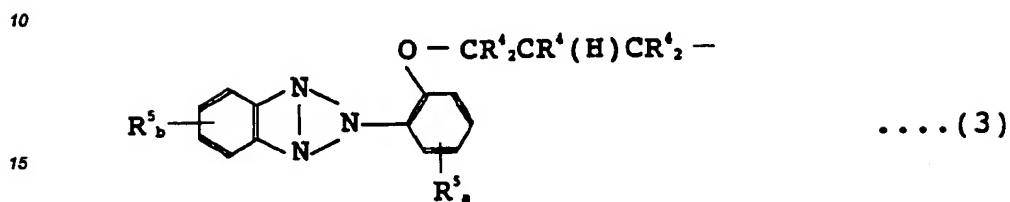
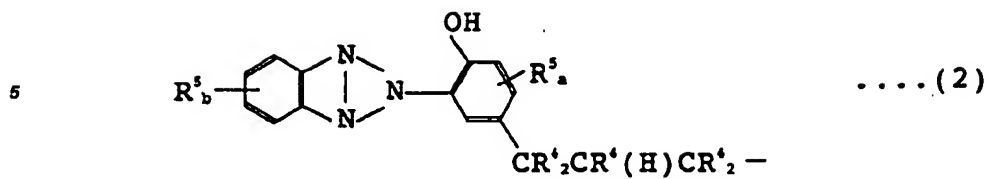
As is evident from these formulations, the organic silicon compounds of the present invention are effective additives to cosmetic compositions.

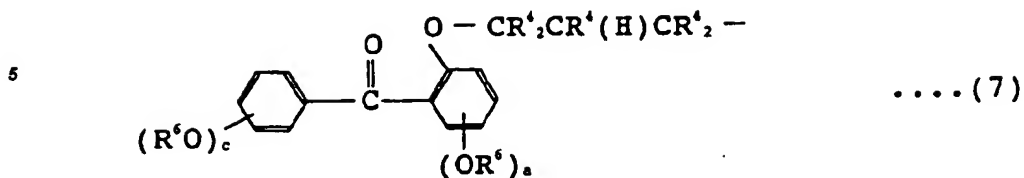
Although some preferred embodiments have been described, many modifications and variations may be made thereto in the light of the above teachings. It is therefore to be understood that within the scope of the appended claims, the invention may be practiced otherwise than as specifically described.

Claims

1. An organic silicon compound having a benzotriazole or benzophenone skeleton, comprising $R^1_3SiO_{1/2}$ and SiO_2 units as essential units and $R^2SiO_{3/2}$ and R^3_2SiO units as optional units, the amounts of $R^2SiO_{3/2}$ and R^3_2SiO units each ranging from 0 to 20 mol% of the entire compound, the siloxane units being present in a molar ratio: $(R^1_3SiO_{1/2} + R^2SiO_{3/2} + R^3_2SiO)/SiO_2$ of from 0.5 to 1.5, 1 to 33 mol% of the total quantity of the organic groups represented by R^1 , R^2 and R^3 being selected from the groups of the following structural formulae (1) through (7), the remainder being a monovalent saturated or unsaturated organic group having 1 to 18 carbon atoms,







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wherein R^4 is a hydrogen atom or a monovalent saturated hydrocarbon group having 1 to 5 carbon atoms,

R^5 is selected from the group consisting of monovalent saturated or unsaturated organic groups having 1 to 18 carbon atoms, halogen atoms, alkoxy, carboxy, hydroxy, and amino groups,

15 R^6 is a hydrogen atom or a monovalent saturated or unsaturated hydrocarbon group having 1 to 10 carbon atoms,

letter a is an integer of from 0 to 3, b is an integer of from 0 to 4, and c is an integer of from 0 to 5.

2. A cosmetic composition containing an organic silicon compound as set forth in claim 1.

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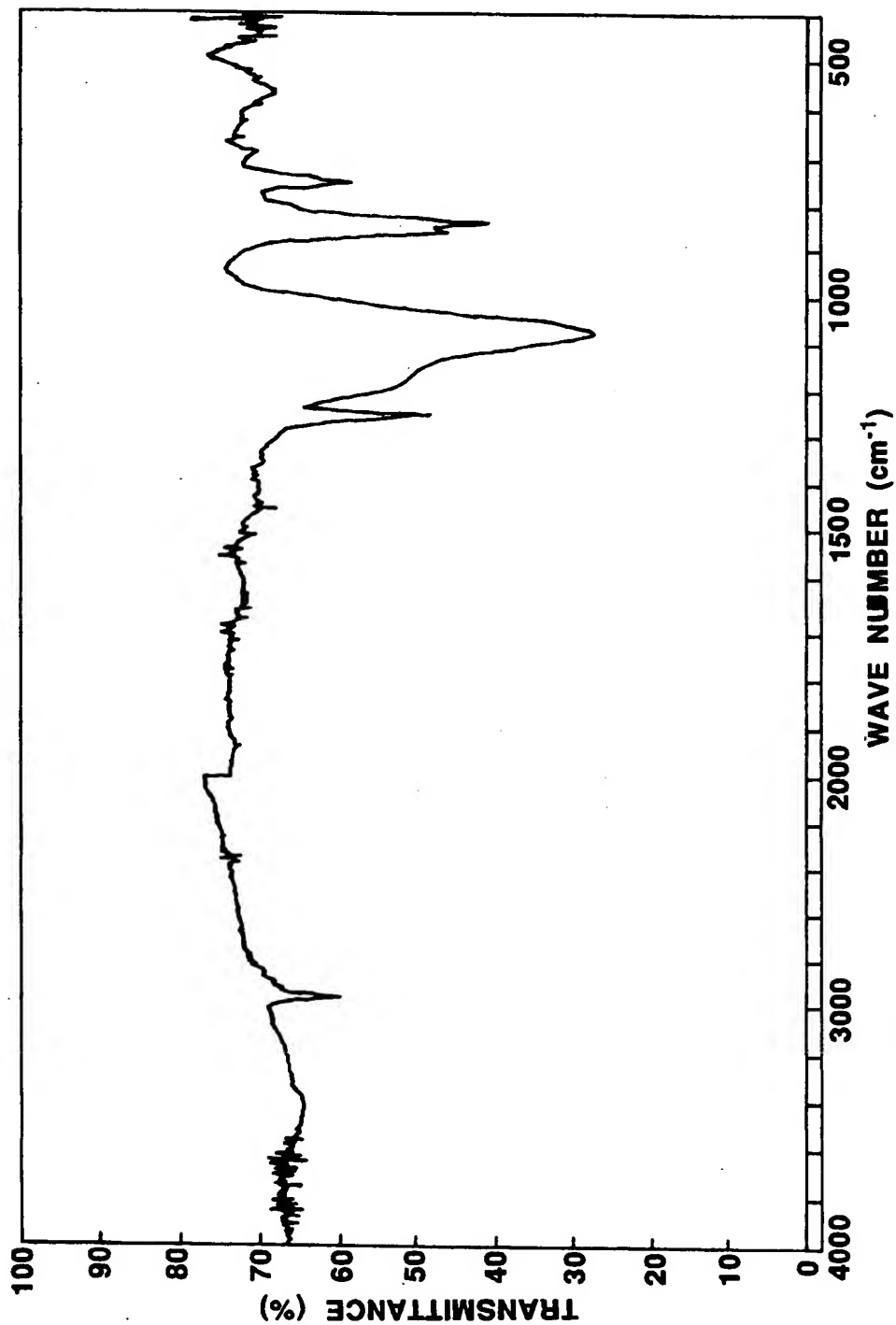
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FIG.1



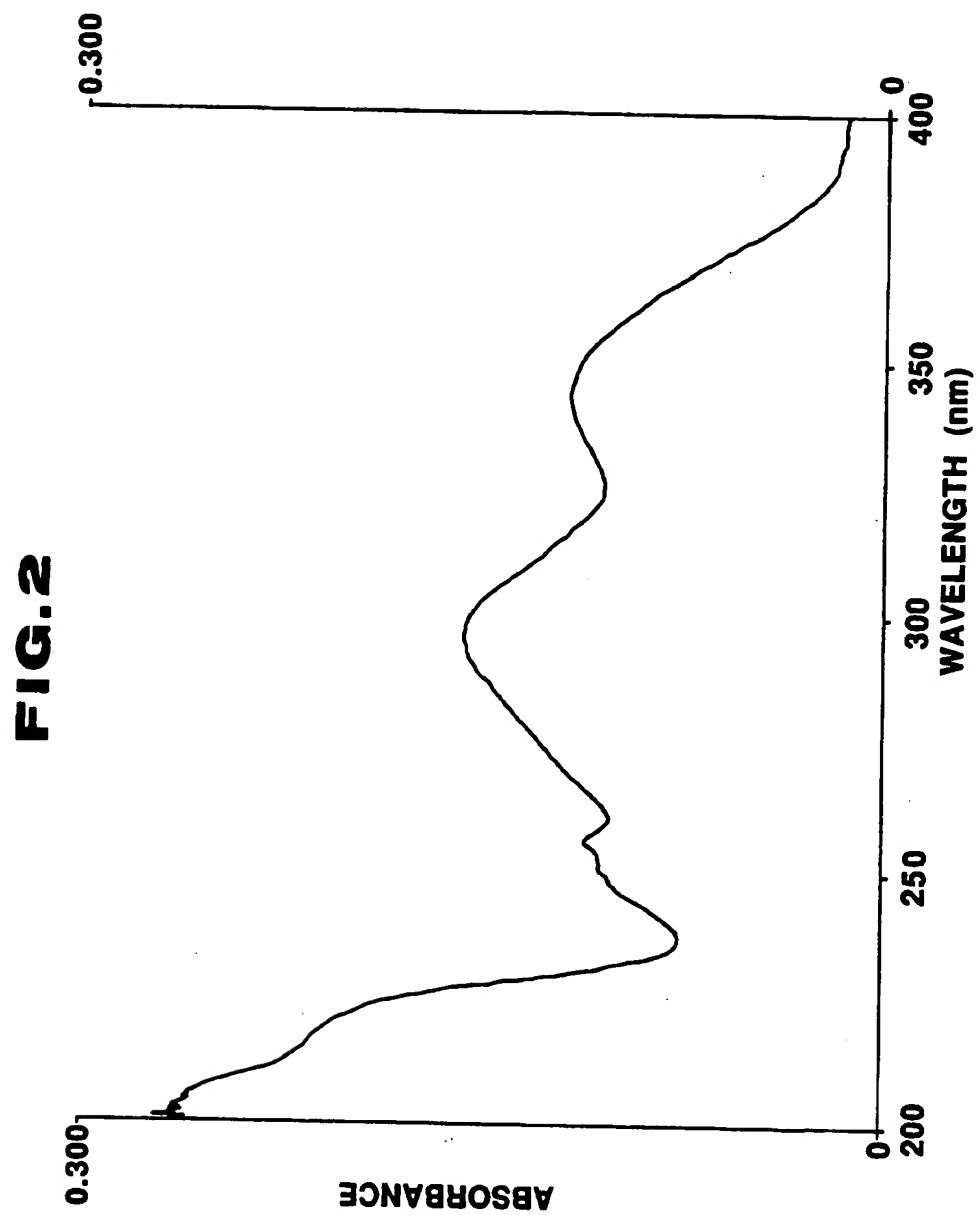


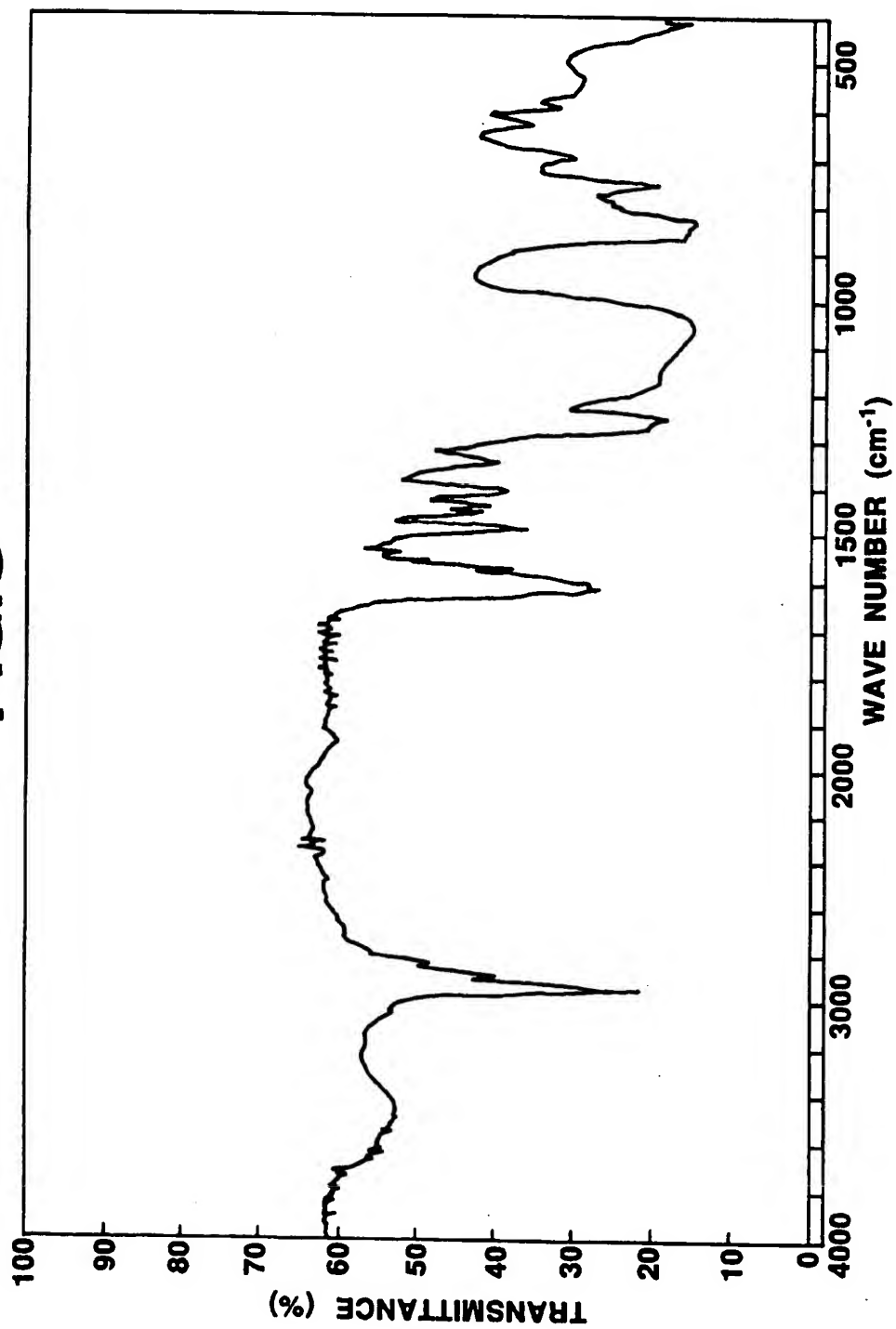
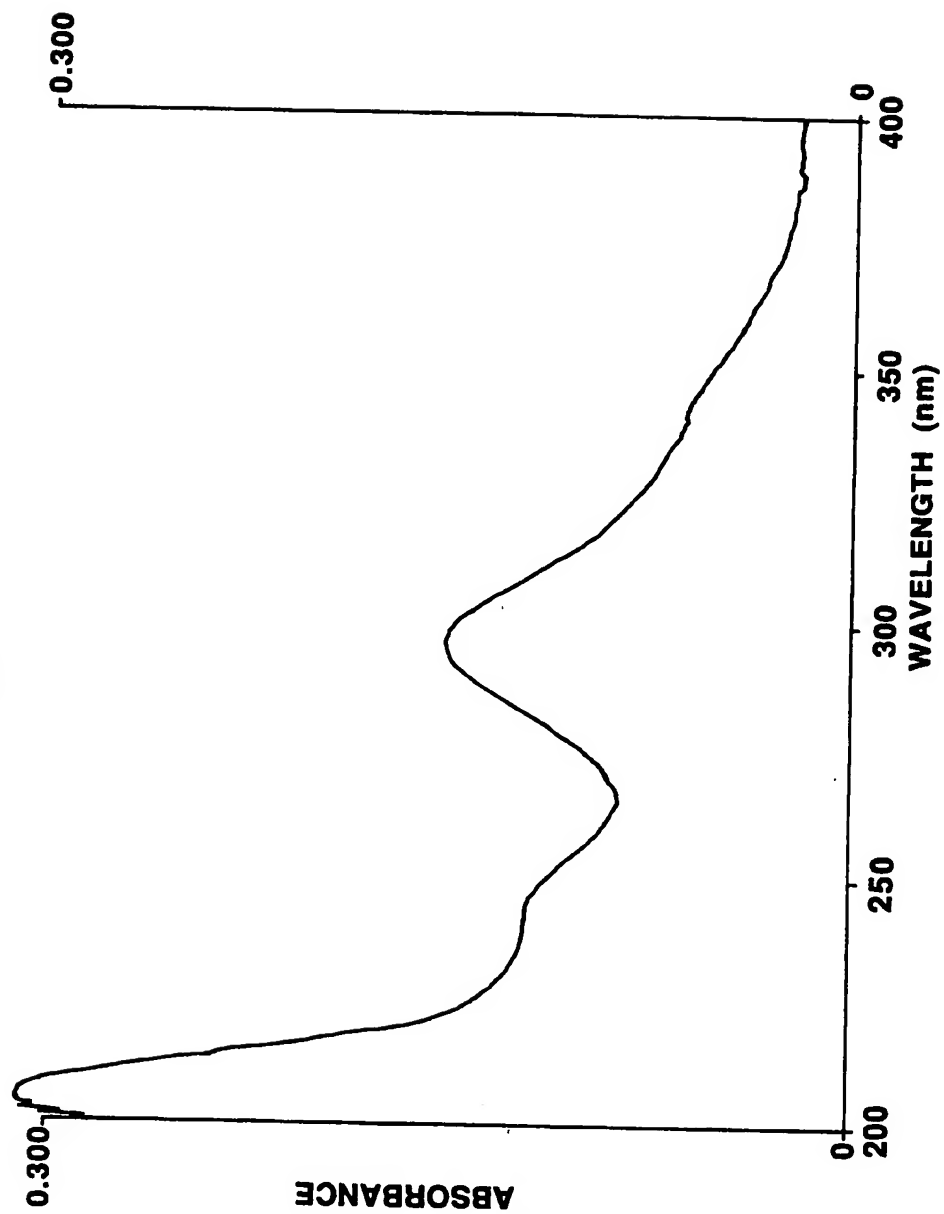
FIG. 3

FIG. 4





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(54) **Organic silicon compounds and cosmetic compositions.**

(57) Novel organic silicon compounds having a UV absorbing benzotriazole or benzophenone skeleton are provided comprising $R^1_3SiO_{1/2}$ and SiO_2 units as essential units, 0 to 20 mol% of $R^2SiO_{3/2}$ and R^3_2SiO units, and 0 to 20 mol% of R^3_2SiO units. The siloxane units are present in a molar ratio : $(R^1_3SiO_{1/2} + R^2SiO_{3/2} + R^3_2SiO)/SiO_2$ of from 0.5 to 1.5. A benzotriazole or benzophenone-bearing group constitutes 1 to 33 mol% of the total quantity of the organic groups represented by R^1 , R^2 and R^3 while the remainder is a monovalent saturated or unsaturated organic group or groups having 1 to 18 carbon atoms. Cosmetic compositions containing the same compounds have improved UV absorbing capacity.

EP 0 478 284 A3



European Patent
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EUROPEAN SEARCH REPORT

Application Number

EP 91 30 8703

DOCUMENTS CONSIDERED TO BE RELEVANT			
Category	Citation of document with indication, where appropriate, of relevant passages	Relevant to claim	CLASSIFICATION OF THE APPLICATION (Int. CLS)
X	GB-A-2 077 280 (GENERAL ELECTRIC COMPANY, STATE OF NEW YORK) * page 2, line 8 - page 3, line 27 * * claims 1,4,6,19; example 2 * ----	1	C08G77/26 C08G77/14 A61K7/00 C07F7/02
X	GB-A-2 078 242 (GENERAL ELECTRIC COMPANY, STATE OF NEW YORK) * claims 1,4,5; examples 1-3 * D & JP-A-57 021 432 (...) ----	1	
X	EP-A-0 088 842 (TORAY SILICONE COMPANY LIMITED) * page 13, line 4 - page 14, line 11 * * page 16, line 10 - page 17, line 2 * * claims 1-3,5; example 1 * ----	1	
A	FR-A-2 642 968 (L'OREAL) * claims 1-19 * ----	2	
P,A	EP-A-0 389 337 (L'OREAL) * claims 1-17 * ----	2	
A	US-A-4 696 969 (R.J. THIMINEUR) * column 5, line 66 - column 6, line 15 * * column 7, line 58 - column 8, line 14 * * column 8, line 50 - line 53; claims 1,2,7,8; example 1 * D & JP-A-61 111 360 (...) -----	1,2	
The present search report has been drawn up for all claims			TECHNICAL FIELDS SEARCHED (Int. CLS)
			C08G A61K C07F
Place of search THE HAGUE		Date of completion of the search 21 FEBRUARY 1992	Examiner KANETAKIS I.
<p>CATEGORY OF CITED DOCUMENTS</p> <p>X : particularly relevant if taken alone Y : particularly relevant if combined with another document of the same category A : technological background O : non-written disclosure F : intermediate document</p> <p>T : theory or principle underlying the invention E : earlier patent document, but published on, or after the filing date D : document cited in the application L : document cited for other reasons ----- & : member of the same patent family, corresponding document</p>			

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